



NEWAY SINOPHC TECH. LIMITED

ADD:RM. 204, BUILDING 3, NO. 188, AONA RD., CHINA (SHANGHAI) PILOT FREE TRADE ZONE.
Email:marketing01@newayphc.com; Phone:+86-021-50350029 <https://www.newayphc.com>

Certificate of Analysis

Product Name: Salvia Miltiorrhiza Extract

Product Information

| Item | Details |
|----------------------|---|
| Product Number | SME-20260209 |
| Batch Number | SME-SH2026020901 |
| Brand | SIGALD |
| CAS Number | 90056-22-1 |
| MDL Number | N/A (Complex plant extract mixture) |
| Formula | Blend of Natural Salvia Miltiorrhiza Extracts (Danshensu, Salvianolic Acid B, Tanshinone IIA) |
| Formula Weight | Variable (Biological mixture) |
| Quality Release Date | 09 FEB 2026 |

Test Results

| Test | Specification (Industry Standard) | Result | Unit | Test Method |
|--------------------------------------|-----------------------------------|-----------------------|-------|---|
| Appearance (Color) | Light brown to dark brown | Light brown | - | Visual Inspection |
| Appearance (Form) | Fine amorphous powder | Fine amorphous powder | - | Visual Inspection |
| Salvianolic Acid B Content | ≥ 10.0% | 11.5% | % | High Performance Liquid Chromatography (HPLC) |
| Tanshinone IIA Content | ≥ 2.0% | 2.3% | % | High Performance Liquid Chromatography (HPLC) |
| pH Value (1% aqueous solution, 25°C) | 5.0-7.0 | 6.1 | - | Digital pH Meter |
| Loss on Drying | ≤ 5.0% | 2.7% | % | 105°C, 3 hours |
| Heavy Metals (Pb) | ≤ 5 ppm | 0.8 ppm | ppm | Atomic Absorption Spectrometry (AAS) |
| Heavy Metals (As) | ≤ 1 ppm | 0.2 ppm | ppm | Atomic Fluorescence Spectrometry (AFS) |
| Total Bacterial Count | ≤ 100 CFU/g | 18 CFU/g | CFU/g | Plate Count Method |
| E. coli | Negative | Negative | - | Microbiological Detection |
| Ash Content | ≤ 5.0% | 2.4% | % | 550±25°C Ignition Method |
| Supplier Information | Confirmed | Confirmed | - | - |
| Registered Trademark | Confirmed | Confirmed | - | - |

Certification

This batch of product has been tested in accordance with industrial standards for salvia miltiorrhiza extract and meets all specified requirements. It is qualified for use.

Issue Date: 09 FEB 2026